



# Immersed- $B_z$ Diode Research on RITS at Sandia

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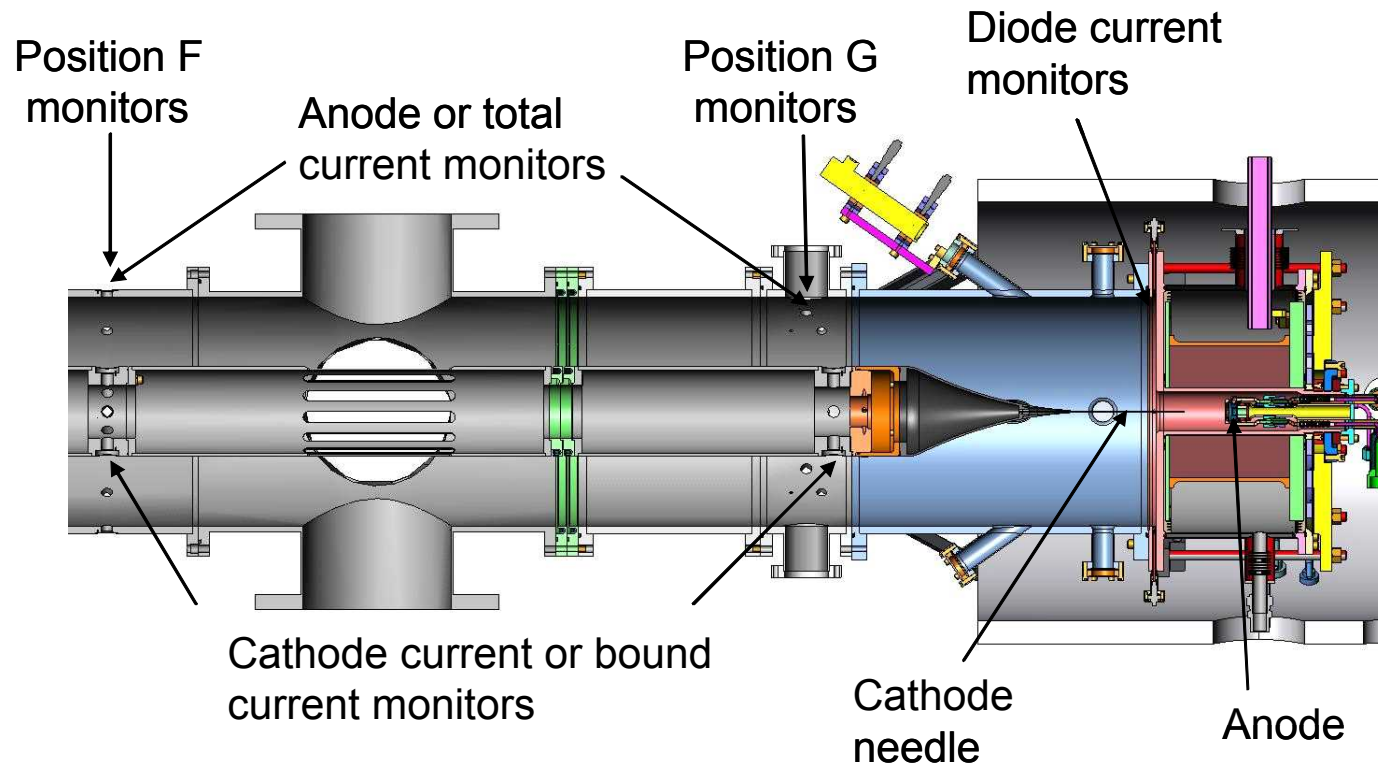


# Immersed- $B_z$ Diode Research

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- Identified two different operating regimes
  - Nominal
  - Anomalous
- Investigated the effects of cryogenic modifications to anode surface

# Immersed- $B_z$ Diode on RITS-3



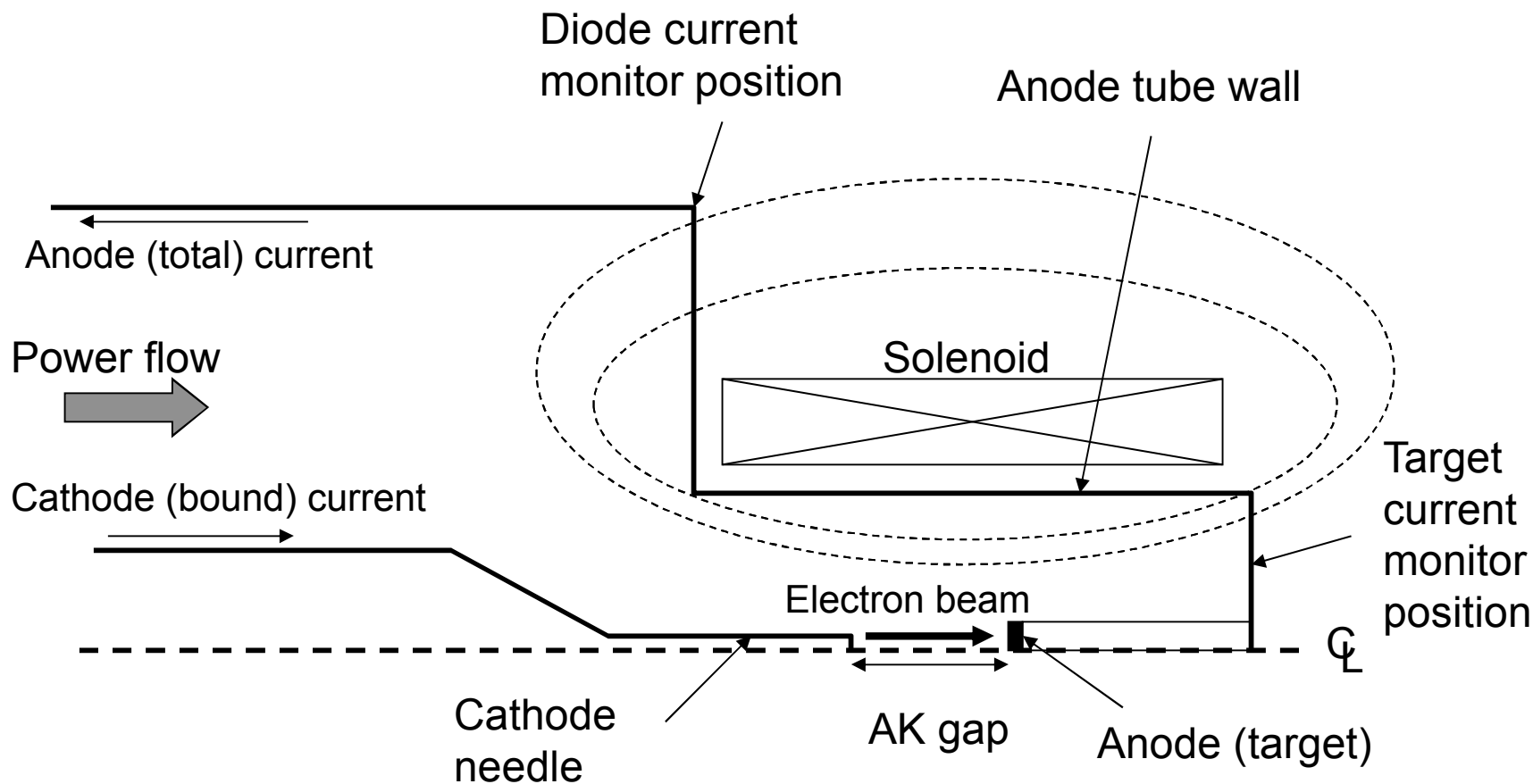
## RITS-3 Parameters:

**V : 4 - 5 MV**

**I (total) : 120 – 150 kA**

**t: 70 ns FWHM**

# Immersed- $B_z$ Diode Schematic





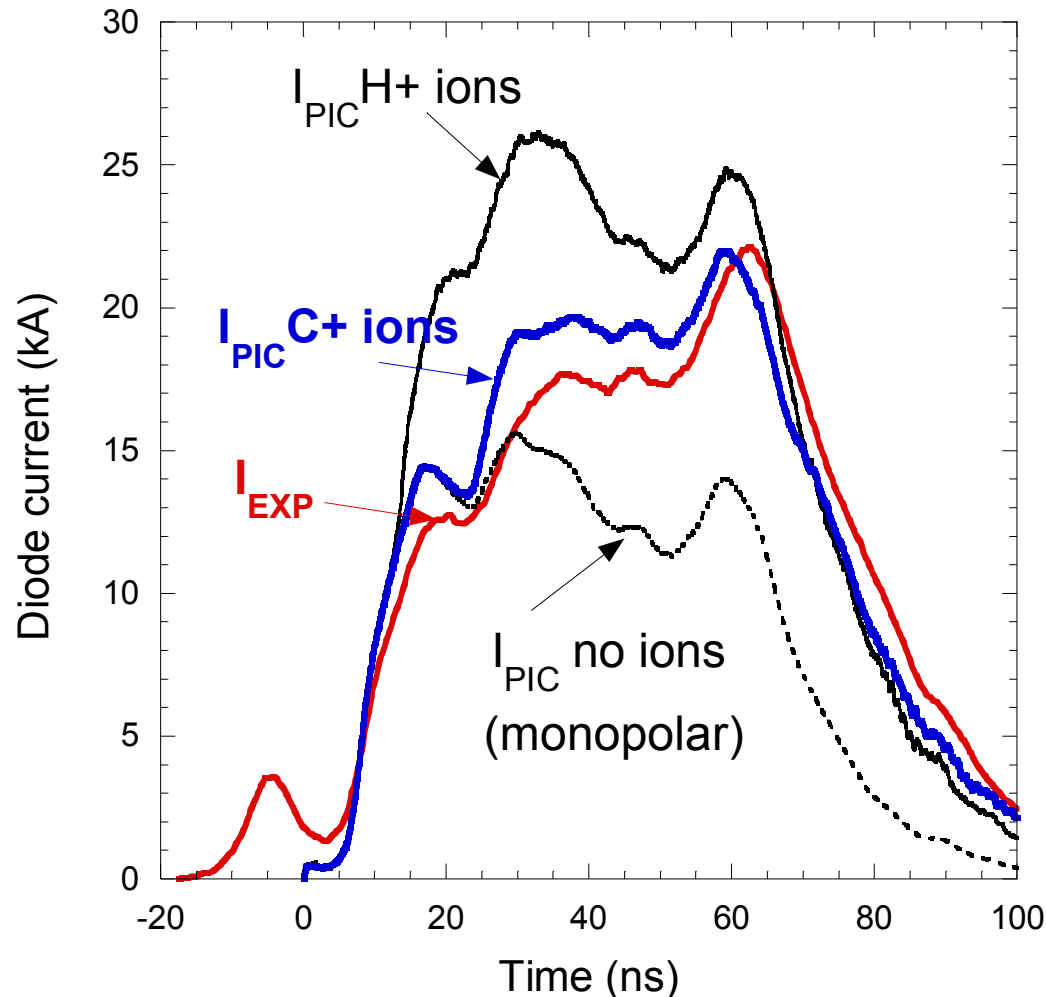
# Nominal operating regime characteristics

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- Large cathode diameters  $> 4$  mm
- Diode current
  - 20 – 40 kA
  - Bipolar flow (electrons and ions)
  - Agrees well with numerical simulation
- Dose production
  - Agrees well with physics-based model
- Spot size
  - Scales with cathode diameter

# Nominal regime diode current

## Comparison of 2D Lsp PIC simulations with experiment



### Shot 288

- Cathode dia. = 4.76 mm
- AK gap = 10 cm
- Bz field = 18 T
- Anode = RT Ta

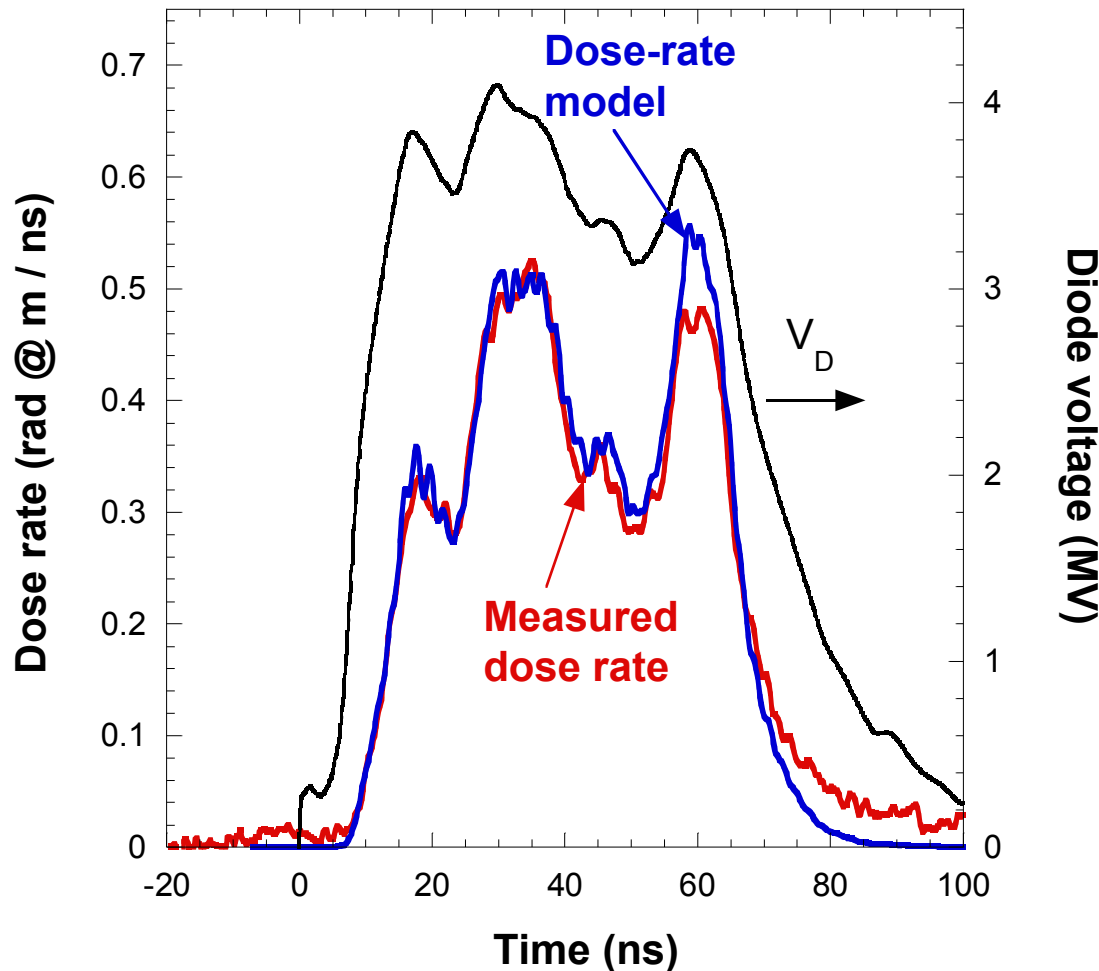
### Lsp simulation

- 2D
- 400 K  $\Delta T$  ion turn-on
- Space charge limited
- Electron backscatter

**Experimental current  
is best replicated with  
medium-mass ion  
simulation (C+ ions)**

# Nominal regime dose production

## Comparison of dose-rate model with experiment



### Shot 288

Cathode dia. = 4.76 mm

AK gap = 10 cm

Bz field = 18 T

Anode = RT Ta

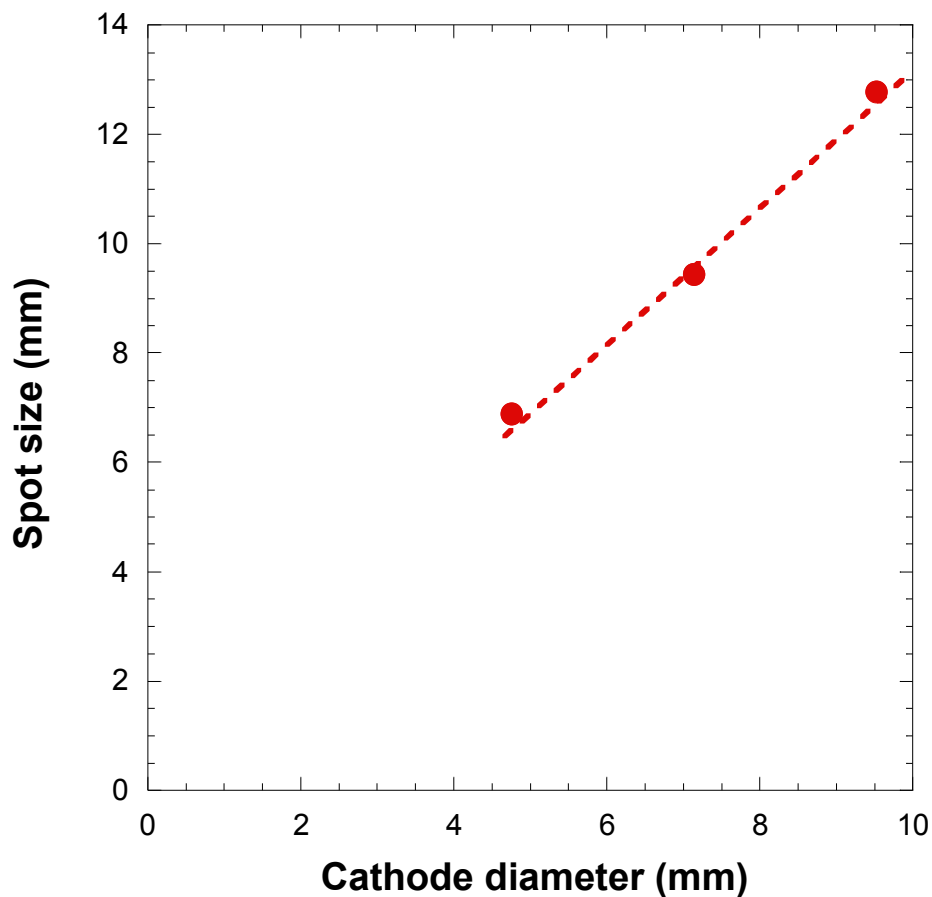
### Dose-rate model:

$$dD/dt = 1.25 I V^{2.3}$$

**Measured dose rate  
agrees well with  
model**

# Nominal regime spot size

## Spot size scales with cathode diameter



**Shots 288, 339, 345**

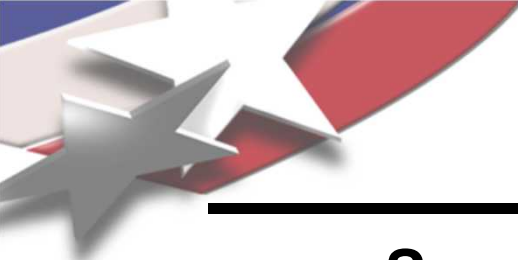
**V = 4 MV**

**AK gap = 10 cm**

**Bz field = 18 T**

**Anode = RT Ta**





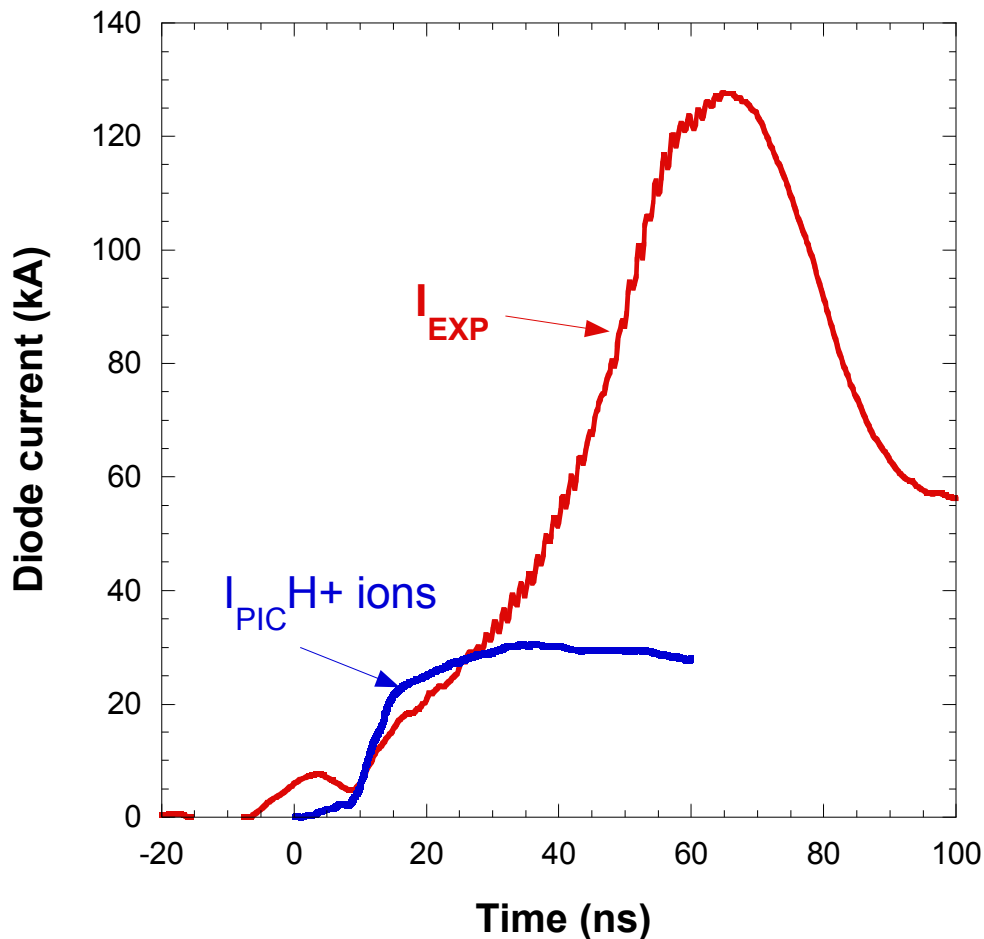
# Anomalous operating regime characteristics

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- Small cathode diameters  $< 3$  mm
- Diode current
  - $> 80$  kA
  - Rapidly exceeds bipolar current
  - Dramatic impedance collapse
- Dose production
  - Narrow pulse
  - Rapid departure from physics-based model
- Spot size
  - Does not scale with cathode diameter

# Anomalous regime diode current

## Comparison of 2D Lsp PIC simulations with experiment



### Shot 765

- Cathode dia. = 2 mm
- AK gap = 7.1 cm
- Bz field = 20 T
- Anode = RT Ta

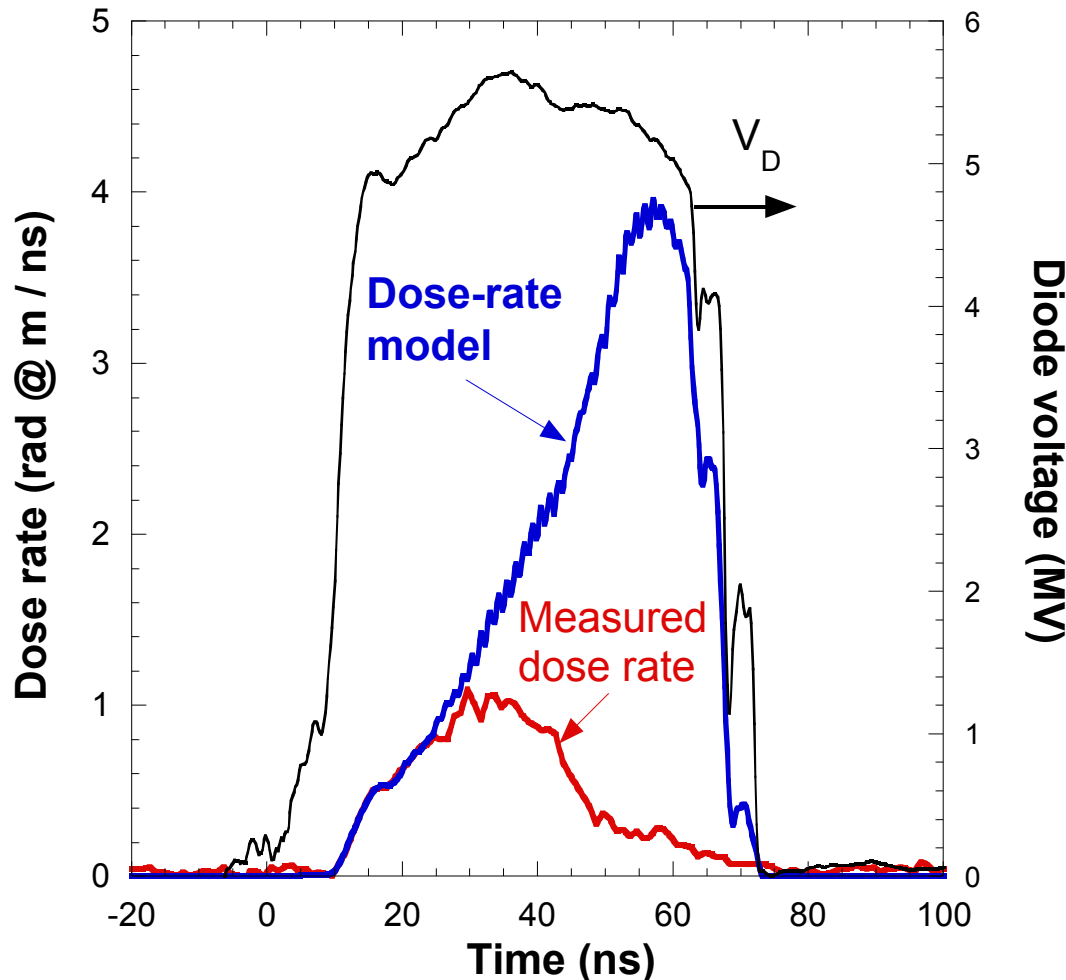
### Lsp simulation

- 400 K  $\Delta T$  ion turn-on
- Space charge limited
- Electron backscatter

**Experimental current quickly exceeds calculated bipolar current (H+ ions)**

# Anomalous regime dose production

## Comparison of dose-rate model with experiment



### Shot 765

Cathode dia. = 2 mm

AK gap = 7.1 cm

Bz field = 20 T

Anode = RT Ta

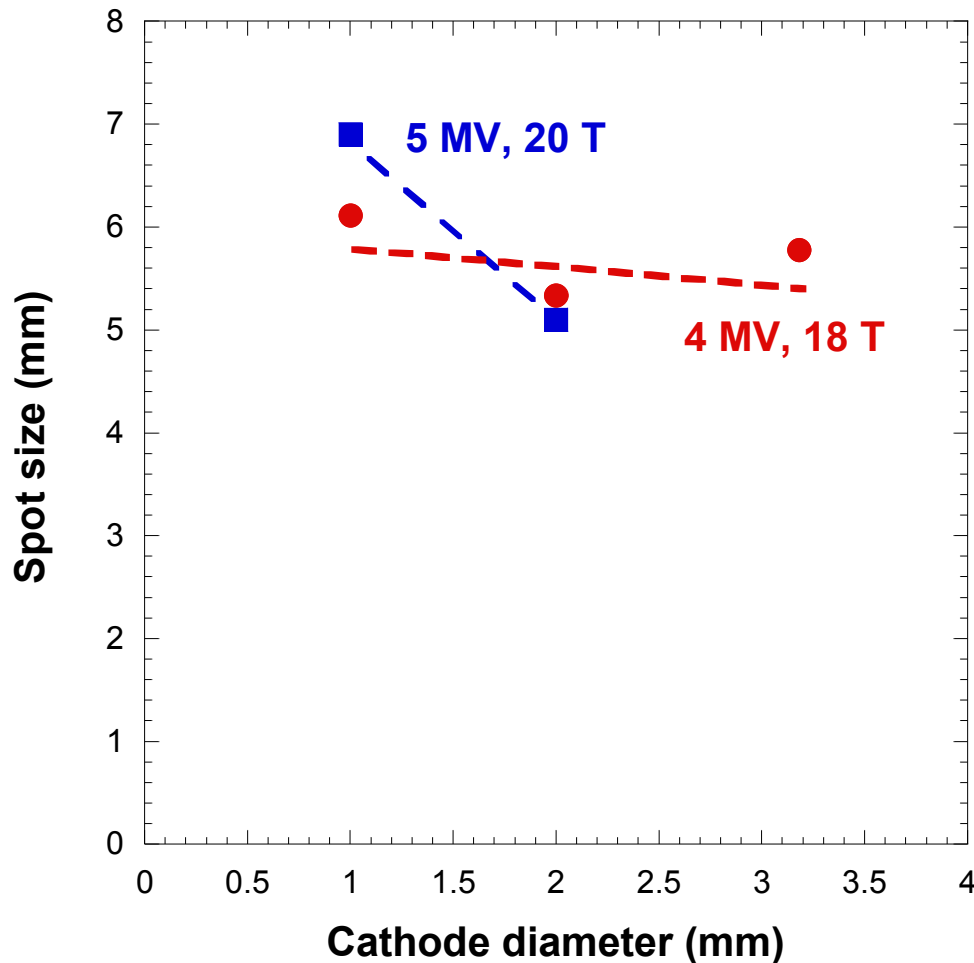
### Dose-rate model:

$$dD/dt = 0.75 I V^{2.3}$$

**Measured dose rate quickly diverges from dose-rate model**

# Anomalous regime spot size

Spot size does not scale with cathode diameter



4 MV, 18 T  
Shots 287, 291, 341  
AK gap = 10 cm  
Anode = RT Ta

5 MV, 20 T  
Shots 765, 766  
AK gap = 7.1 cm  
Anode = RT Ta

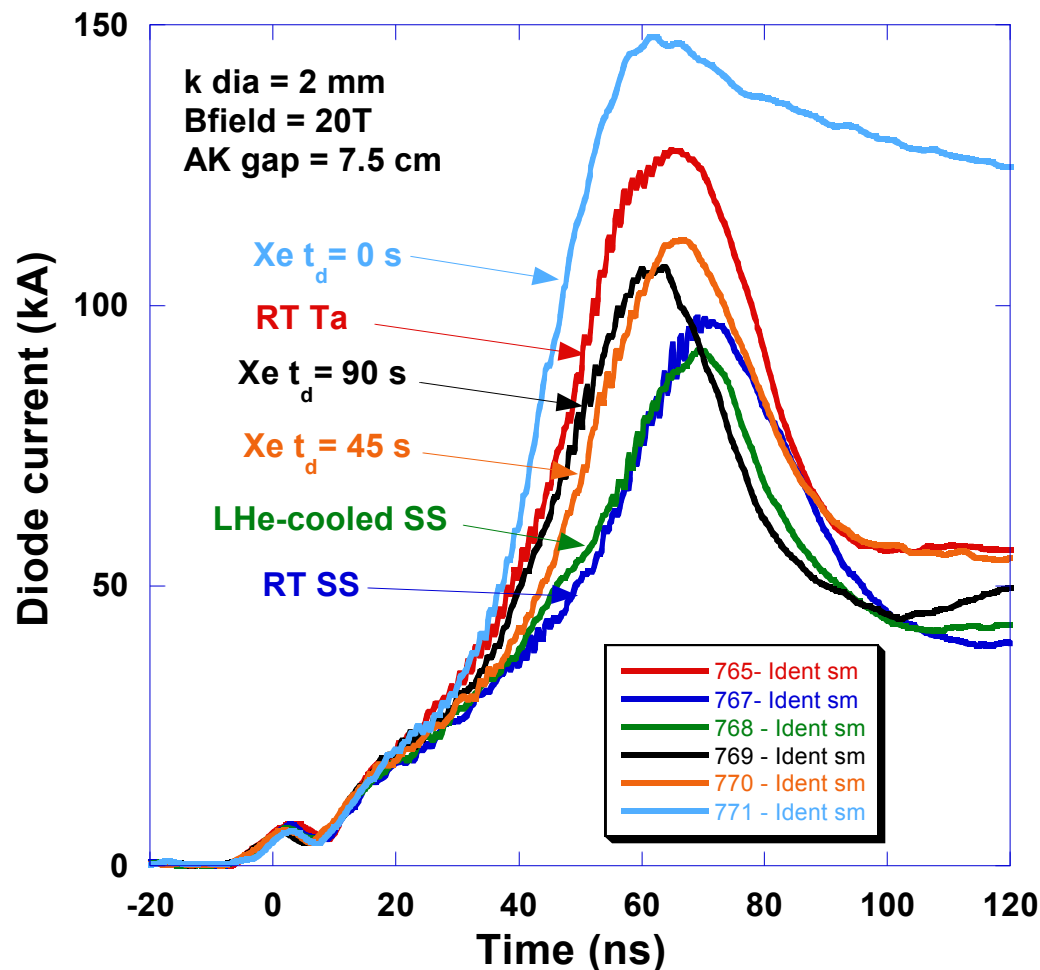


# Cryogenic Modification of Anodes

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- **Attempt to modify behavior of small cathodes by controlling ion species from anode**
  - **Frozen Xe coated anodes**
- **No significant change in diode behavior, i.e. no change in**
  - **Diode current**
  - **Dose production**
  - **Spot size**
- **Dramatic change observed in cathode activation**
  - **Suggests significant decrease in protons from anode**

# Effect of cryogenic modification of anode on diode current



## Xenon coatings:

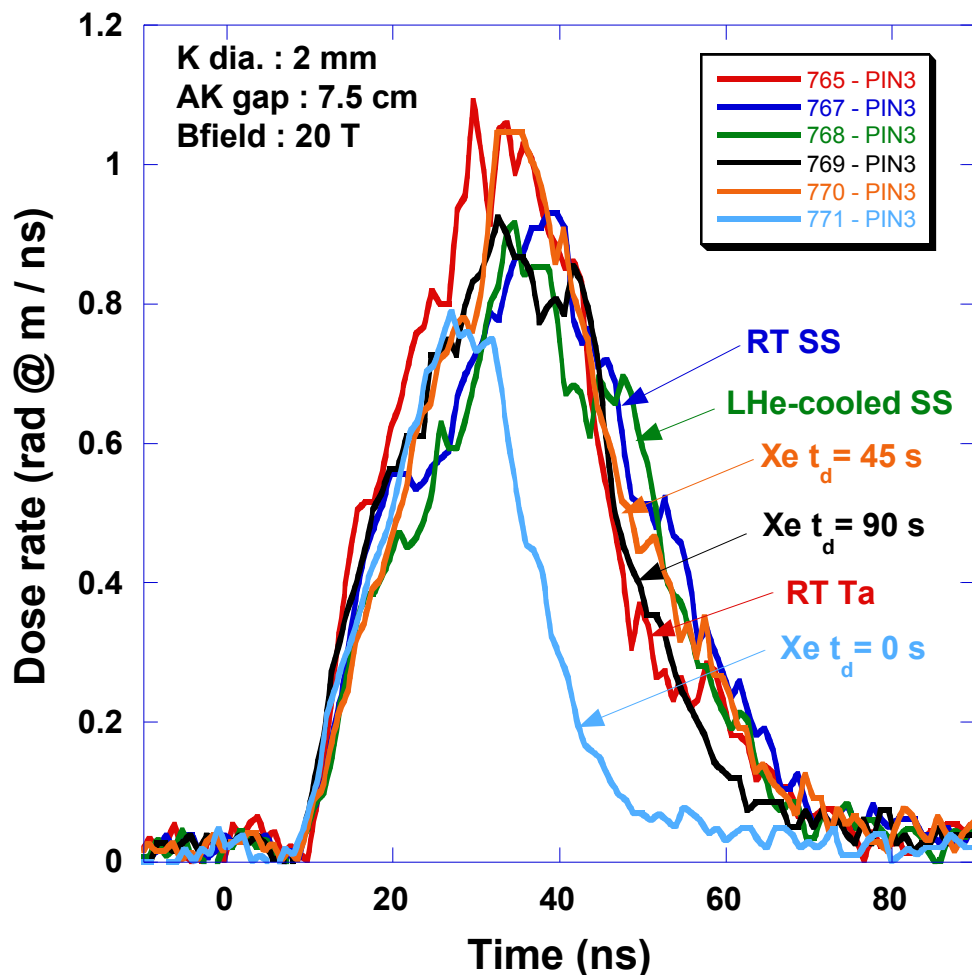
Effective thickness > 300 microns

Effective coating rate > 0.5  $\mu\text{m} / \text{s}$

$t_d$ : Time delay between gas supply shut-off and experiment

**No significant effect  
on diode current**

# Effect of cryogenic modification of anode on dose production



## Xenon coatings:

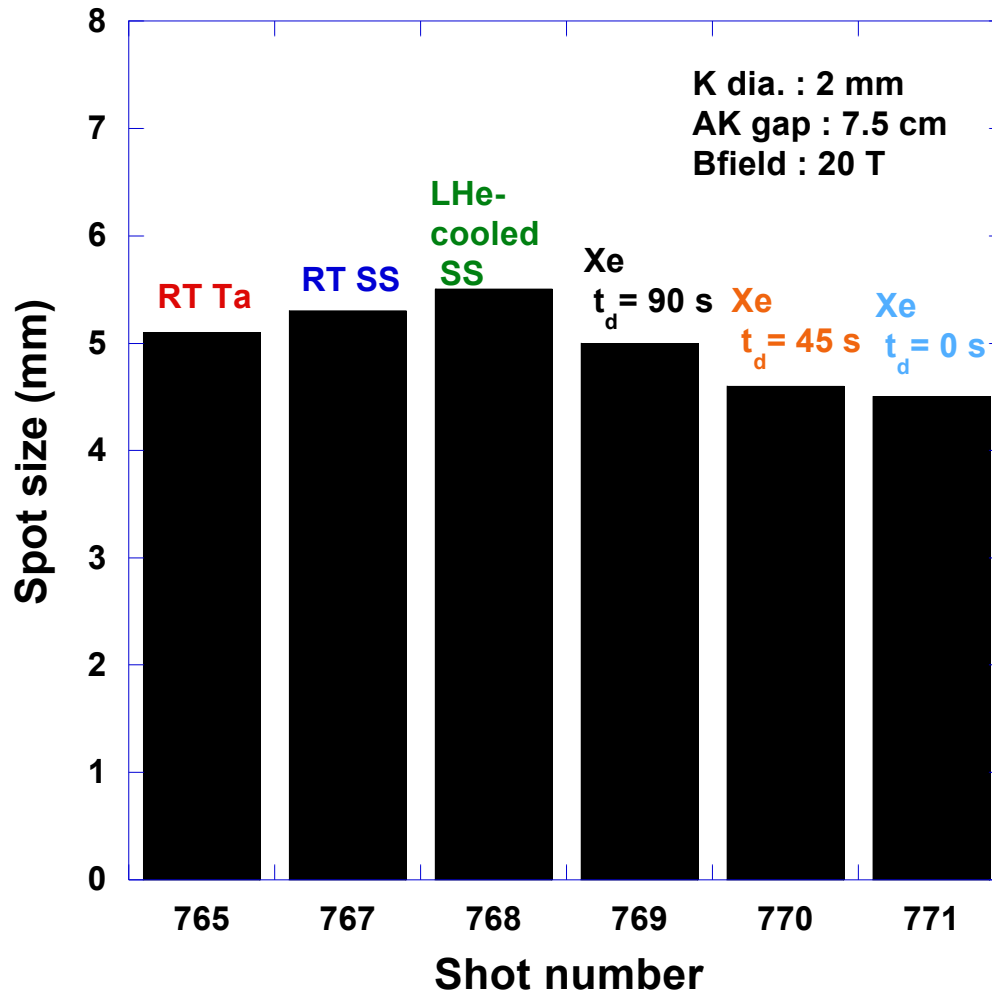
Effective thickness > 300 microns

Effective coating rate > 0.5  $\mu\text{m} / \text{s}$

$t_d$ : Time delay between gas supply shut-off and experiment

**No significant effect  
on dose production**

# Effect of cryogenic modification of anode on spot size



## Xenon coatings:

Effective thickness > 300 microns

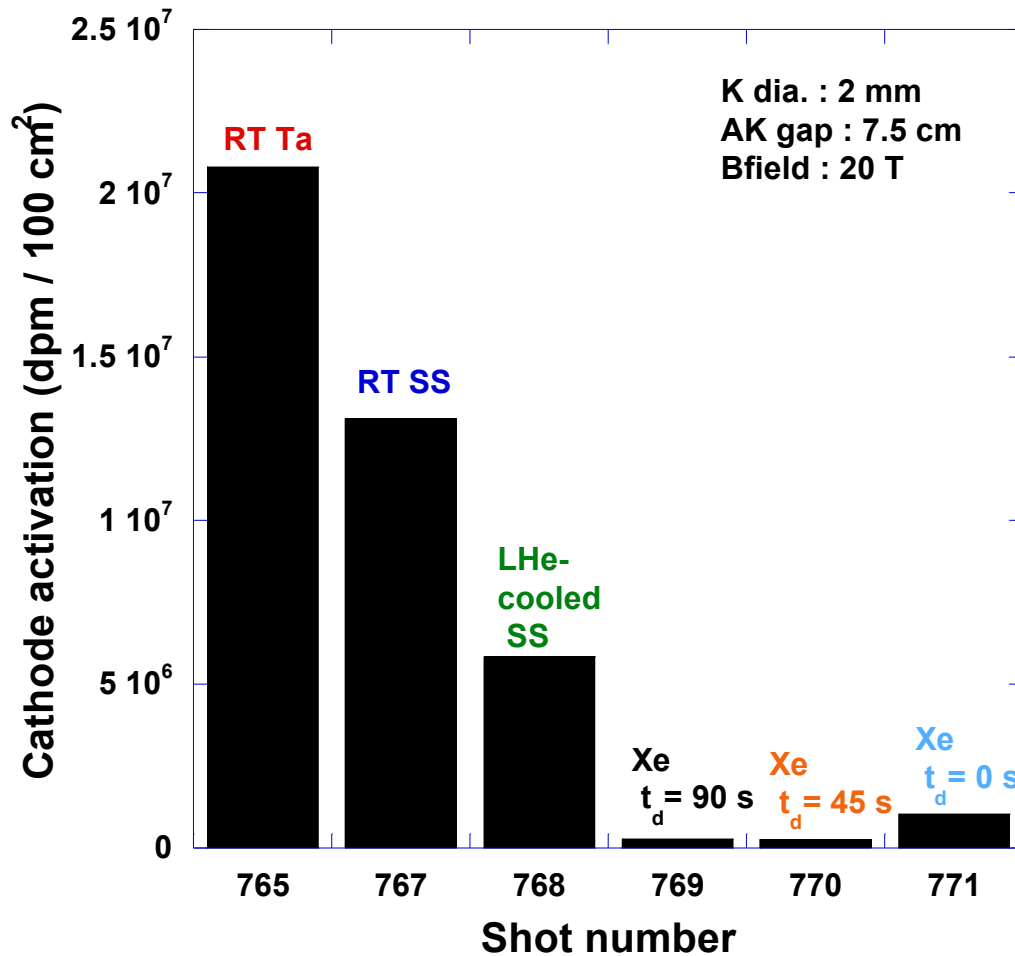
Effective coating rate > 0.5  $\mu\text{m} / \text{s}$

$t_d$ : Time delay between gas supply shut-off and experiment

**No significant effect  
on spot size**



# Effect of cryogenic modification of anode on cathode activation



## Xenon coatings:

Effective thickness > 300 microns

Effective coating rate > 0.5  $\mu\text{m} / \text{s}$

$t_d$ : Time delay between gas supply shut-off and experiment

## Cathode material:

Titanium alloy: Ti-6Al-4V

**Dramatic decrease in cathode activation suggests decreased proton content from anode**



# Summary

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- **Identified two different operating regimes**
  - **Nominal**
  - **Anomalous**
- **Nominal diode currents agree well with medium-mass ion simulations**
- **Anomalous diode behavior remains unchanged with cryogenic modifications to anode**
- **Cause of anomalous diode behavior remains unclear**
- **Improved understanding will require increased utilization of plasma diagnostics**